

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	((("5584898") or ("5895583"))).PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 12:33
L2	5778	(polish\$3 or abrad\$3 or planariz\$3) same (silicon adj carbide or "SiC")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 12:36
L3	457	2 same ((silica or silicon adj oxide) same (abrasive or particle))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 12:50
L4	296	3 same diamond	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 12:38
L5	166	4 and @pd<"20020802"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 12:41
L6	22	5 and (mix\$3 same ratio)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 12:42
L7	711	2 same (bond\$3 or join\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 12:51
L8	28	7 and ((diamond same silica) same abrasive)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 15:15
L9	28	7 and ((diamond same silica) same (abrasive or particle))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:41
L10	3	(wafer same (molecular near bond\$3)) same 2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:45

L11	49	(wafer same (molecular near bond\$3)) same (polish\$3 or abrad\$3 or lapp\$3 or planariz\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:57
L12	38	11 and (abrasive or particle or grit)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:47
L13	23	12 and (diamond same silica or silicon adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:51
L14	1	12 and (diamond same silica)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:52
L15	4192	(wafer same bond\$3) same (polish\$3 or abrad\$3 or lapp\$3 or planariz\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:58
L16	4	15 same ((diamond same silica) same (abrasive or particle or grit))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 14:59
L17	792	((diamond same silica) same abrasive)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 15:17
L18	259	17 and ((polish\$3 or smooth\$3 or planariz\$3 or lapp\$3 or abrad\$3) same wafer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 15:18
L19	46	17 same ((polish\$3 or smooth\$3 or planariz\$3 or lapp\$3 or abrad\$3) same wafer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 15:19
L20	19	19 and ((bond\$3 or join\$3 or attach\$3) same wafer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 15:40

L21	56	letertre-fabrice.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 15:41
L22	25	letertre-fabrice.in.	US-PGPUB; USPAT	OR	OFF	2005/02/17 15:41
L23	13	(silicon near wafer) same (molecular near bond\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:17
L24	11	23 and (polish\$3 or lapp\$3 or abrad\$3 or smooth\$3 or planariz\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:24
L25	531	(grind\$3 or polish\$3) same ((before or prior) near bond\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:26
L26	0	25 same (silica same abrasive)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:26
L27	5	25 and ((silica same abrasive) same diamond)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:27
L28	223	slurry same (diamond same silica)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:40
L29	37	28 same (wafer same polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:40
L30	75	28 same ((silicon adj carbide) same (polish\$3 or grind\$3 or lapp\$3 or abrading))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:50
L31	44	30 and (wafer same smooth\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:51

L32	44	30 and ((wafer same smooth\$3) same polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 16:53
L33	41	32 and (bond\$3 or join\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/17 17:02
L34	13	438/455.ccls. and 18	US-PGPUB; USPAT	OR	OFF	2005/02/17 17:03